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INFORMATION DISCLOSURE STATEMENT BY APPLICANT (37 CFR 1.98(b))				Applicant HARALD KUHN ET AL.								
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MILL	L	0 389 533 B1 —	10/3/90	Europe								
VI/AA	M	09 142 995 A	6/3/97	Japan								
iW	N	10 182 296 A	7/7/98	Japan								
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)												
MA	J	Yoo, W. et al.: "Bulk Crystal Growth of 6H-SiC on Polytype-Controlled Substrates Through Vapor Phase and Characterization", Elsevier Science Publishers B.V., 1991, pp. 733-739;										
MA	'	Takahashi, J. et al.: "Influence of the Seed Face Polarity on the Sublimation Growth of α-SiC", Jpn. J. Appl. Phys., Vol. 34, Part 1, No. 9A, September 1995, pp. 4694-4698;										
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OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)										
MA	•	Jayatirtha, H. et al.: "Improvement in the Growth Rate of Cubic Silicon Carbide Bulk Single Crystals grown by the sublimation Method", Elsevier Science B.V., 1997, pp. 662-668;								
MA		Ohtani, N. et al.: "Development of Large Single-Crystal SiC Substrates", Scripta Jechnica, 1998, pp. 8-17;								
EXAMINER MATTEU LULIU DATE CONSIDERED 29103										
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